

## PAPER

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# Lead-free and amorphous organic–inorganic hybrid materials for photovoltaic applications: mesoscopic $\text{CH}_3\text{NH}_3\text{MnI}_3/\text{TiO}_2$ heterojunction†

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As one type of organic–inorganic hybrid material,  $\text{APbX}_3$  organic–inorganic lead perovskite materials have attracted considerable attention in optoelectronic applications. Although organic–inorganic lead perovskites possess high solar-to-electrical conversion efficiency, the toxic Pb in organic–inorganic lead perovskites is expected to cause environmental pollution in future mass applications. Thus, exploiting Pb-free organic–inorganic hybrid materials is urgently needed. In this study, a lead-free and amorphous  $\text{CH}_3\text{NH}_3\text{MnI}_3$  (a-MAMnI<sub>3</sub>) thin film was prepared by spin coating a mixed  $\text{MnI}_2$  and MAI precursor solution on an electronic transport layer (ETL)- $\text{TiO}_2$ . A mesoscopic a-MAMnI<sub>3</sub>/ $\text{TiO}_2$  heterojunction was formed by filling the mesoporous  $\text{TiO}_2$  layer with MAMnI<sub>3</sub>. The architecture of the optoelectronic device is FTO/ETL- $\text{TiO}_2$ /a-MAMnI<sub>3</sub>/Spiro-MeOTAD/Ag. The photovoltage of the optoelectronic device based on the mesoscopic a-MAMnI<sub>3</sub>/ $\text{TiO}_2$  heterojunction reached 300 mV under AM1.5, 100  $\text{mW cm}^{-2}$  simulated illumination. The evident photoresponse was observed at 530 nm green light. The test with 2000 s on/off cycling indicated the good stability and repeatability of the device. The findings pave a way for realizing Pb-free and amorphous organic–inorganic hybrid materials applied to optoelectronic logic devices, photodetectors, and optical memory devices.

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## Introduction

Organic–inorganic hybrid materials have attracted significant attention as functional layers for optoelectronic applications<sup>1</sup> because of their superior charge carrier mobility for inorganic semiconductors and their solution processability.<sup>2</sup> At present, organic–inorganic hybrid materials present promising performance in solar cells,<sup>3</sup> field-effect transistors,<sup>4</sup> light-emitting diodes,<sup>5</sup> upconversion emission,<sup>6</sup> and so on. Notably, as one type of organic–inorganic hybrid material,  $\text{ABX}_3$  organic–inorganic perovskite materials have received serious consideration all over the world because of the high solar-to-electrical conversion efficiency of organic–inorganic perovskite solar cells. Since 2012, the solar-to-electrical conversion efficiency of organic–inorganic lead (Pb) perovskites has increased from 3.9% (ref. 7) to 21%,<sup>8</sup> which is close to that of commercial silicon solar cells.

Although organic–inorganic lead perovskites possess high solar-to-electrical conversion efficiency,<sup>8</sup> tunable bandgap,<sup>9,10</sup> high carrier mobility,<sup>11,12</sup> and low exciton binding energy (14–25 meV),<sup>13,14</sup> many problems remain, and they include stability,<sup>15,16</sup> reproducibility,<sup>8,17</sup> and anomalous hysteresis.<sup>18,19</sup> Furthermore, the toxic Pb content of organic–inorganic lead perovskites is expected to cause environmental pollution in future mass applications. Thus, exploiting new substitutes for organic–inorganic Pb perovskites is urgently needed. In recent years, a number of groups, including the authors of the present work, have focused on developing and investigating Pb-free organic–inorganic hybrid materials, including  $\text{MASnI}_3$ ,<sup>20,21</sup>  $\text{AGeI}_3$  (A = Cs, MA, or FA),<sup>22</sup> and  $\text{MA}_2\text{MnCl}_4$ .<sup>23</sup> However, Ge and Sn are easily oxidized, leading to device degradation. Organic–inorganic (manganese) hybrid materials, such as (pyrrolidinium) $\text{MnCl}_3$ ,<sup>24</sup>  $[(\text{CH}_3)_2\text{NH}_2]\text{Mn}(\text{HCOO})_3$ ,<sup>25</sup>  $\text{MA}_2\text{-MnCl}_4$ ,<sup>23</sup>  $[\text{Mn}_2(\text{BPTCA})(\text{phen})_2\cdot\text{H}_2\text{O}]_n$ ,<sup>26</sup> and  $\text{Mn}(\text{C}_6\text{H}_8\text{O}_4)(\text{H}_2\text{O})$ ,<sup>27</sup> have been developed into various functional materials for ferroelectricity,<sup>26</sup> luminescence,<sup>24</sup> photocatalysis<sup>28</sup> and magnetic applications.<sup>29</sup> In our previous report, incarnate  $\text{MA}_2\text{MnCl}_4$  presented ultraviolet photoresponse.<sup>23</sup> If halide is changed in  $\text{MA}_2\text{MnCl}_4$ , then the optical bandgap may be tuned and device performance may be improved. With the aforementioned motivation, we aim to investigate the photoresponse of MAMnI<sub>3</sub> thin films for opto-electronic applications.

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In this study, a Pb-free and amorphous  $\text{MAMnI}_3$  (a- $\text{MAMnI}_3$ ) thin film was prepared by spin coating mixed  $\text{MnI}_2$  and MAI precursor solution on an electronic transport layer (ETL)- $\text{TiO}_2$ . Mesoscopic a- $\text{MAMnI}_3/\text{TiO}_2$  heterojunction was formed by filling the mesoporous  $\text{TiO}_2$  layer with a- $\text{MAMnI}_3$ . The architecture of the optoelectronic device comprised FTO/ETL- $\text{TiO}_2$ /a- $\text{MAMnI}_3$ /Spiro-MeOTAD/Ag. The photovoltage of the optoelectronic device based on the a- $\text{MAMnI}_3$  film reached 300 mV under AM1.5, 100  $\text{mW cm}^{-2}$  simulated illumination.

Compared with  $\text{MA}_2\text{MnCl}_4$  materials exhibiting ultraviolet photoresponse, the a- $\text{MAMnI}_3$ -based device presented obvious photoresponse not only to ultraviolet light but also to visible light. The evident photoresponse was observed at 530 nm green light. Finally, the test with 2000 s on/off cycling indicated the good stability and repeatability of the device.

## Experimental section

### Synthesis of MAI

MAI was synthesized following our previous report.<sup>30</sup>

### Fabrication and characterizations of FTO/ETL- $\text{TiO}_2$ /a- $\text{MAMnI}_3$ /Spiro-MeOTAD/Ag devices

Patterned FTO-coated glass substrates with a sheet resistance of 15  $\Omega \text{ sq}^{-1}$  were coated with a  $\text{TiO}_2$  compact layer by spin-coating the  $\text{TiO}_2$  organic sol at 3000 rpm. for 30 s, followed by drying at 450  $^\circ\text{C}$  for 30 minutes, following our previous literature.<sup>31</sup> The mesoporous  $\text{TiO}_2$  layer was coated with a commercial  $\text{TiO}_2$  paste (Dyesol 18NRT, Dyesol) diluted in ethanol (1 : 3.5, weight ratio) by spin coating at 5000 rpm. for 30 s, followed by gradually heated to 500  $^\circ\text{C}$ , baked at this temperature for 30 min. The a- $\text{MAMnI}_3$  layer was prepared by spin coating a mixed precursor solution comprising 1.0  $\text{mol L}^{-1}$   $\text{MnI}_2$  and 1.0  $\text{mol L}^{-1}$  MAI on ETL- $\text{TiO}_2$ . At 3000 rpm. for 30 s, followed by gradually heated to 100  $^\circ\text{C}$ , baked at this temperature for 30 min. The Spiro-MeOTAD hole transport material (HTM) were spin-coated on FTO/ETL- $\text{TiO}_2$ /a- $\text{MAMnI}_3$  substrate at 3000 rpm for 30 s using HTMs/1,2-dichlorobenzene (72.3  $\text{mg mL}^{-1}$ ) with 17.5  $\mu\text{L}$  Li-bis(trifluoromethanesulfonyl)imide (Li-TFSI)/acetonitrile (28.3  $\text{mg mL}^{-1}$ ), 29  $\mu\text{L}$  tris(2-(1H-pyrazol-1-yl)-4-*tert*-butylpyridine) cobalt(III) bis(trifluoromethylsulphonyl)imide and 28.8  $\mu\text{L}$  TBP as additives. Finally, silver (50 nm) was vacuum deposited on top of the device to form the back contact. Nanostructures of films and devices were characterized by scanning electron microscopy (SEM, Hitachi SEM S-4800). UV-vis absorption spectrum was obtained using UV/vis/NIR spectrometer (Perkinelmer, lambda, 750S). The photocurrent-voltage performances of the device with 0.12  $\text{cm}^2$  photo-electrode were measured by a Keithley digital source meter (Keithley 2400, USA) and equipped with a solar simulator (IV5, PV Measurements, Inc., USA). The photocurrent-time performance of the device was carried out by an electrochemical workstation system (CHI760, Chenhua, and Shanghai) and equipped with a solar simulator (IV5, PV Measurements, Inc., USA). The photocurrent-time with incident photon (wavelength) and frequency response were measured by an

electrochemical workstation system (CHI760, Chenhua, and Shanghai) and equipped with a quantum efficiency/spectral response (SR)/incident photon to current conversion efficiency (IPCE) measurement system (QEX10, PV Measurements, Inc., USA).

## Results and discussions

Solution-processed optoelectronic devices are cost effective to manufacture and offer physical flexibility. Perovskite nanopigments are notably easy to prepare and deposit through simple solution processing *via* spin coating or dip coating. The preparation process of ETL- $\text{TiO}_2$ /a- $\text{MAMnI}_3$  thin films is shown in Fig. 1. The preparation process of ETL- $\text{TiO}_2$ , including a compact layer and mesoporous  $\text{TiO}_2$  layer, is described in our previous report.<sup>31</sup> ETL- $\text{TiO}_2$  was colorless and transparent. The yellow film was formed after spin coating a mixed precursor solution comprising 1.0  $\text{mol L}^{-1}$   $\text{MnI}_2$  and 1.0  $\text{mol L}^{-1}$  MAI on ETL- $\text{TiO}_2$ . The film was labelled as MAI/ $\text{MnI}_2$  film. After heating on a hot plate at 100  $^\circ\text{C}$ , the yellow MAI/ $\text{MnI}_2$  film became a dark brown film, which was labelled as a- $\text{MAMnI}_3$  film. The UV-vis absorption spectra were used to investigate the aforementioned absorption properties of the thin film. FTO/ETL- $\text{TiO}_2$  films exhibit an absorption peak at 400 nm. The absorption intensity of the ultraviolet region increases from 300 nm to 355 nm, whereas the weak absorption intensity ranges from 450 nm to 800 nm. The absorption intensity of MAI/ $\text{MnI}_2$  thin films was slightly stronger than that of FTO/ETL- $\text{TiO}_2$  films. The UV-vis absorption intensity of a- $\text{MAMnI}_3$  was significantly enhanced.

The difference absorbance ( $\Delta\text{Absorbance}$ ) between the absorbance of FTO/ETL- $\text{TiO}_2$ /a- $\text{MAMnI}_3$  and FTO/ETL- $\text{TiO}_2$  is shown in Fig. 1b and c. The a- $\text{MAMnI}_3$  film presented a distinct absorption peak at 370 nm and an absorption edge at 762 nm. The classic  $\text{MAPbI}_3$  perovskite material shows an absorption edge at 750 nm (Fig. 1d) because the absorption edge is directly related to the bandgap. The result indicates that the bandgap of the a- $\text{MAMnI}_3$  film was similar to that of  $\text{MAPbI}_3$ . However, the absorption intensity of a- $\text{MAMnI}_3$  was not as strong as that of  $\text{MAPbI}_3$  perovskite, hence the low photoelectric response in the succeeding results. In order to determine the phase structure of  $\text{MAMnI}_3$ , we carried out the XRD test. The result was shown in Fig. S1 in (ESI†). Compared with FTO/ $\text{TiO}_2$ , no new diffraction peaks was observed for MAI/ $\text{MnI}_2$  films after heat treatment, which indicated that films were amorphous films. In addition, the thin film was prepared by spin coating a mixed precursor solution comprising  $\text{MnI}_2$  and MAI with mole ratio 1 : 1, followed by gradually heated to 100  $^\circ\text{C}$  to evaporating solvent. Thus, the thin film can be named amorphous  $\text{MAMnI}_3$ . We can decide the organic-inorganic perovskite structure simply through the tolerance factor ( $t$ ),  $t = (r_A + r_X) / [(2^{1/2} (r_B + r_X))]$ , where  $r_A$ ,  $r_B$ , and  $r_X$  are the ionic radii of A, B, and X, respectively. The ionic radius of  $\text{Pb}^{2+}$  and  $\text{Mn}^{2+}$  are 119 and 80 pm, respectively. Thus, the value of tolerance factor for  $\text{MAMnI}_3$  is 0.94. The value of tolerance factor for  $\text{MAPbI}_3$  is 0.834. The reason for why the crystalline  $\text{MAMnI}_3$  cannot form may be high tolerance factor ( $t$ ) and short bond length of Mn-I in  $\text{MnI}_6^-$ .



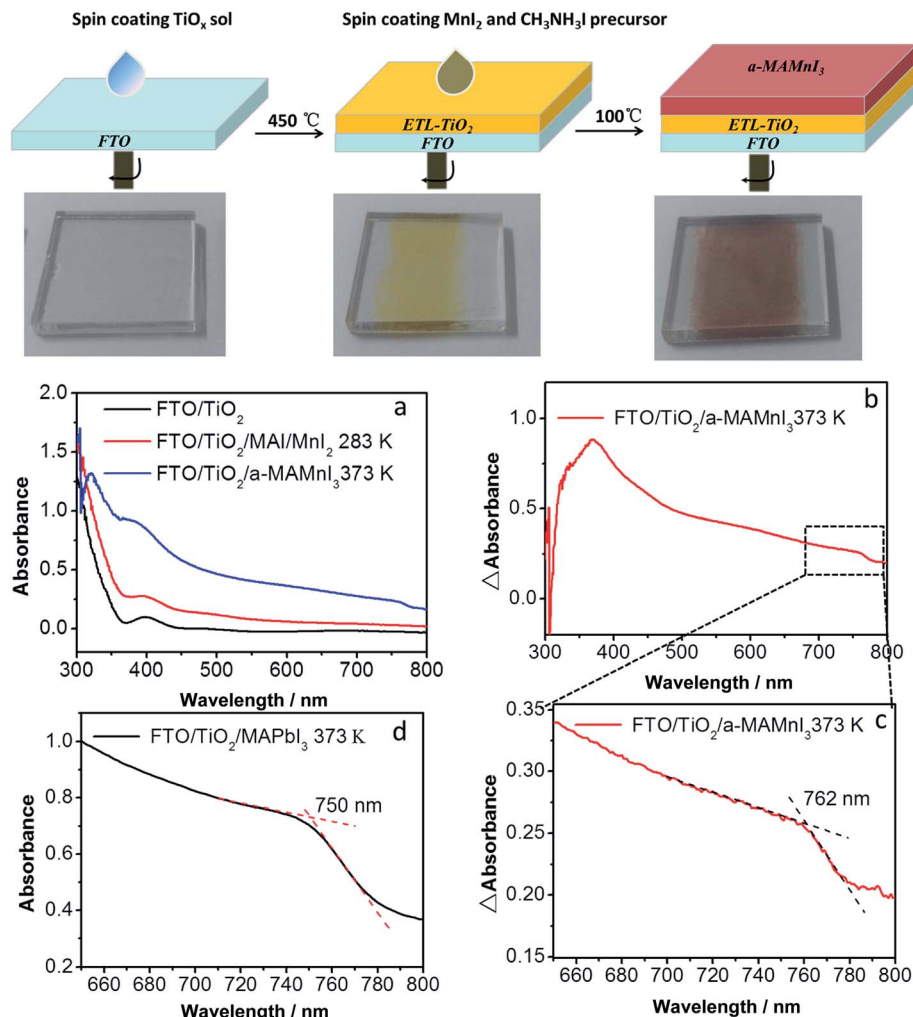


Fig. 1 Schematics of the solution-processed  $\text{TiO}_2$  electronic transport layer (ETL) and a-MAMnI<sub>3</sub> thin film. (a) UV-vis absorption spectrum of FTO/ $\text{TiO}_2$ , FTO/ $\text{TiO}_2$ /MAI/ $\text{MnI}_2$  283 K and FTO/ $\text{TiO}_2$ /a-MAMnI<sub>3</sub> 373 K; (b) difference absorbance between FTO/ $\text{TiO}_2$ /a-MAMnI<sub>3</sub> 373 K and FTO/ $\text{TiO}_2$ ; (c) amplified plot from 650 nm to 800 nm of (c); (d) UV-vis absorption spectrum of FTO/ $\text{TiO}_2$ /a-MAPbI<sub>3</sub> 373 K.

Scanning electron microscopy (SEM) was performed to study the micro-morphology of the thin films. The mesoporous  $\text{TiO}_2$  layer presented a mesoporous distribution (Fig. 2a), which favored increases in the adsorption capacity of the sensitizer and in photoelectric response efficiency. The surface morphology of a-MAMnI<sub>3</sub> on the mesoporous  $\text{TiO}_2$  layer is shown in Fig. 2b to determine whether a-MAMnI<sub>3</sub> is embedded into the mesoporous  $\text{TiO}_2$  layer. The figure shows that the a-MAMnI<sub>3</sub> precursor solution is indeed embedded in the mesoporous  $\text{TiO}_2$  layer. Some islands were formed by the excess a-MAMnI<sub>3</sub> precursor solution on the mesoporous  $\text{TiO}_2$  layer. In addition, the mesoporous  $\text{TiO}_2$  layer was not completely covered with the a-MAMnI<sub>3</sub> film. This condition was expected to cause short-circuit contact between the ETL- $\text{TiO}_2$  and the hole transport layer, increase electron recombination, and weaken the photoelectric performance. The reason of the mesoporous  $\text{TiO}_2$  not completely covered with the a-MAMnI<sub>3</sub> film is that infiltration of the precursor solution on the  $\text{TiO}_2$  film is not good. In fact, we have made some improvement measures to improve

coverage, such as increasing temperature of the precursor and  $\text{TiO}_2$  thin film to improve coverage. However, coverage has not improved significantly. In addition, the solvent and deposition method will also affect the coverage. In the future study, we will intend to change the solvent DMF to  $\gamma$ -butyrolactone, or prepare the a-MAMnI<sub>3</sub> film by sequential deposition method. The surface element distribution of the a-MAMnI<sub>3</sub> film was measured *via* EDS in SEM, as shown in Fig. 2c. The results show that the element distribution of Mn, I, C, and N in the micro-region is uniform.

The preparation process of the optoelectronic devices is shown in Fig. 3. The bandgap of the a-MAMnI<sub>3</sub> thin film was close to that of MAPbI<sub>3</sub>; hence, a p-type hole transport material, Spiro-MeOTAD, was spin-coated on the a-MAMnI<sub>3</sub> film. Then, back-electrode Ag was prepared *via* vacuum thermal evaporation. The architecture of the optoelectronic device comprised FTO/ETL- $\text{TiO}_2$ /a-MAMnI<sub>3</sub>/Spiro-MeOTAD/Ag. The cross section SEM of the device is shown in Fig. 3a. The thicknesses of the FTO, dense layer, and metal electrode layer were 398, 34, 48 nm,





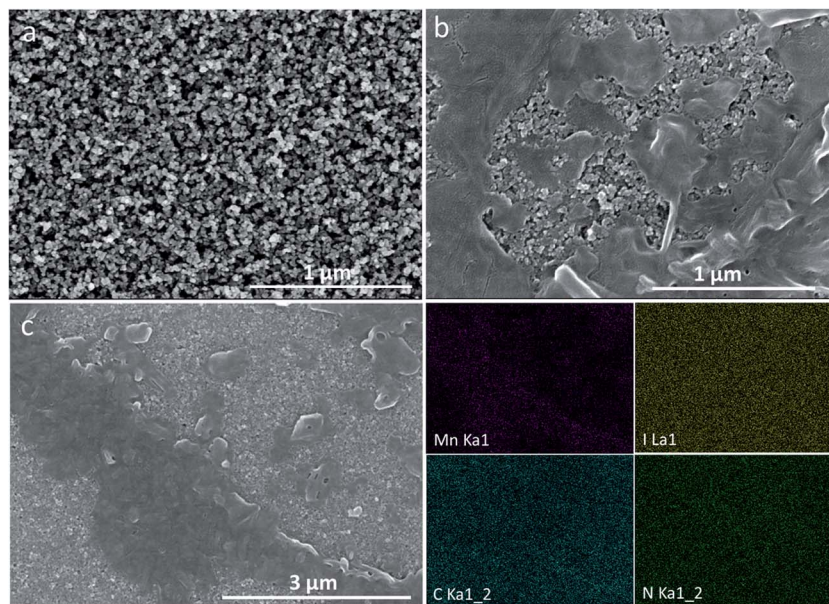


Fig. 2 (a) SEM images of ETL (electronic transport layer)-TiO<sub>2</sub> on FTO; (b) SEM images of a-MAMnI<sub>3</sub> layer on ETL-TiO<sub>2</sub>; (c) energy dispersive X-ray spectra (EDS) mapping of each element for a-MAMnI<sub>3</sub> layer on ETL-TiO<sub>2</sub>.

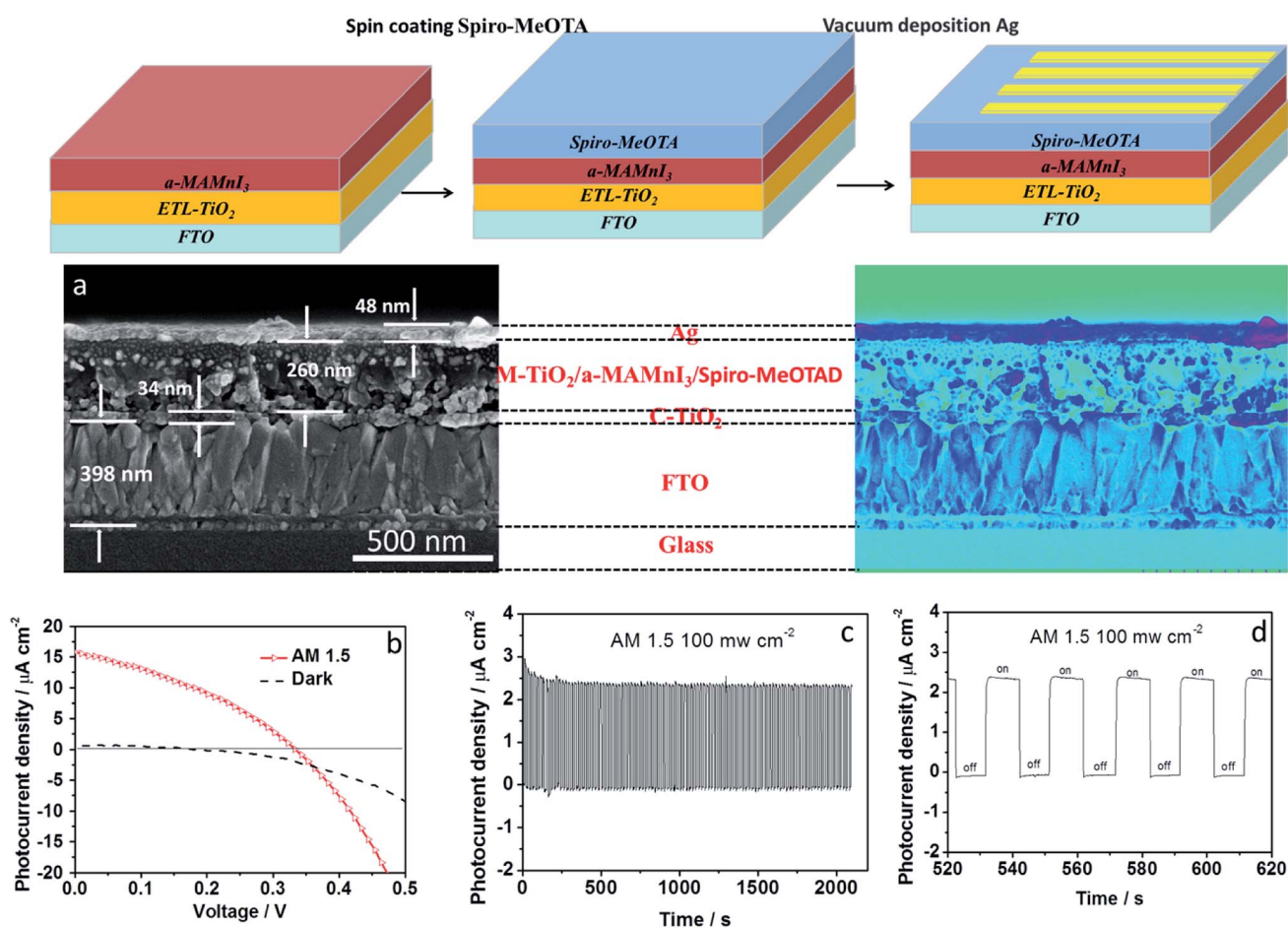


Fig. 3 Schematic diagram of the solution-processed HMT and vacuum deposition Ag on FTO/ETL-TiO<sub>2</sub>/MAMnI<sub>3</sub>; (a) cross-sectional SEM images of FTO/ETL-TiO<sub>2</sub>/a-MAMnI<sub>3</sub>/Spiro-MeOTAD/Ag; (b) the photocurrent–voltage performance of the device were measured under AM1.5, 100 mW cm<sup>-2</sup> simulated illumination; (c) photocurrent–time characteristics of the device under AM1.5, 100 mW cm<sup>-2</sup> simulated illumination; (d) amplifying on/off signal in photocurrent–time characteristics.



respectively. The dense layer of  $\text{TiO}_2$  showed uninterrupted coverage, which facilitates effective block hole injection.<sup>32</sup> The MAI/ $\text{MnI}_2$  precursor is soluble in polar organic solvents, such as *N,N*-dimethylformamide. Therefore, it is solution processable and can be transformed into  $\text{TiO}_2$  pores at a molecular level to realize close contacts. The cross-sectional SEM image demonstrates that the Mesoscopic a-MAMnI<sub>3</sub>/ $\text{TiO}_2$  heterojunction was indeed formed with the filling of a-MAMnI<sub>3</sub> into the mesoporous  $\text{TiO}_2$  layer. Initially, the photoelectric performance of FTO/ETL- $\text{TiO}_2$ /a-MAMnI<sub>3</sub>/Spiro-MeOTAD/Ag was obtained under AM1.5, 100  $\text{mW cm}^{-2}$  simulated illumination. The best performance under open circuit voltage of 330 mV, short-circuit current density of 15.8  $\mu\text{A cm}^{-2}$ , filling factor of 0.41 and power conversion efficiency of 0.02% is presented in Fig. 3b. The photoelectric performance based on a-MAMnI<sub>3</sub> was obviously better than that based on  $\text{MA}_2\text{MnCl}_4$ . The on/off photoelectric

response is shown in Fig. 3c and d. When the simulated illumination was switched off, the current density remained at 0  $\mu\text{A cm}^{-2}$  for about 10 s. When the simulated illumination was switched on, the current density instantaneously increased to about 2.4  $\mu\text{A cm}^{-2}$ . The maximum photocurrent density and the minimum photocurrent density of the device were almost unchanged after 2000 s cycling. This result indicated the good stability and repeatability of the device.

The photoelectric responses were investigated at different wavelengths to determine the monochromatic response of photocurrents. The different wavelengths of monochromatic light were obtained and depicted in Fig. 4. The chopping frequency of monochromatic light was 1.33 Hz. In our previous report, we found that the  $\text{MA}_2\text{MnCl}_4$ -based photoresponsive device exhibited ultraviolet photoresponse. However, the a-MAMnI<sub>3</sub>-based photoresponsive device presented obvious

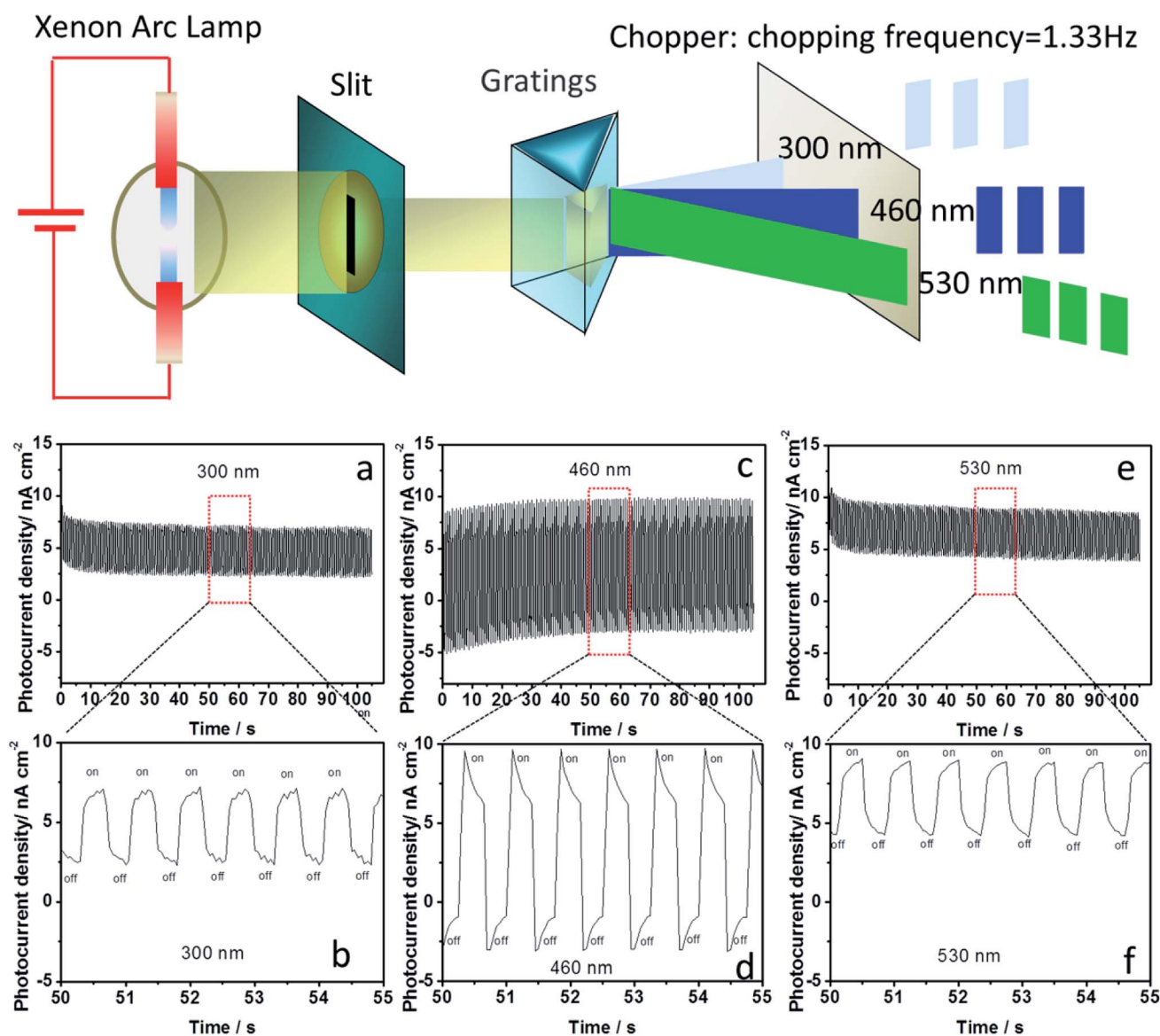


Fig. 4 Schematic diagram of obtaining the different wavelengths of monochromatic light; photocurrent–time characteristics of the FTO/ETL- $\text{TiO}_2$ /a-MAMnI<sub>3</sub>/Spiro-MeOTAD/Ag device under different wavelengths (300, 460 and 530 nm) with 1.33 Hz chopping frequency.



photoresponse not only to 300 nm ultraviolet light but also to 460 nm (blue) and 530 nm (green) visible light (Fig. 4). The large difference ( $I_{\text{on}} - I_{\text{off}}$ ) between the photocurrent intensity under illumination ( $I_{\text{on}}$ ) and that in the dark ( $I_{\text{off}}$ ) is necessary in optoelectronic logic devices. The value of  $I_{\text{on}} - I_{\text{off}}$  at 460 nm was greater than that at 300 and 530 nm. When the wavelength of monochromatic light was increased to 660 nm, the value of  $I_{\text{on}} - I_{\text{off}}$  significantly decreased in Fig. S2 in ESI.† When the wavelength of the monochromatic light was increased to 760 and 860 nm, no photoelectric signal was observed, and the value of  $I_{\text{on}} - I_{\text{off}}$  was close to zero in Fig. S2 in ESI.† The wavelength from 300 nm to 530 nm can be used as effective monochromatic light for a-MAMnI<sub>3</sub> optoelectronic devices.

## Conclusions

In sum, we prepared a Pb-free and amorphous MAMnI<sub>3</sub> thin film *via* the spin coating method. Mesoscopic a-MAMnI<sub>3</sub>/TiO<sub>2</sub> heterojunction was formed with the filling of a-MAMnI<sub>3</sub> into the mesoporous TiO<sub>2</sub> layer. The photovoltage of the optoelectronic device comprising FTO/ETL-TiO<sub>2</sub>/a-MAMnI<sub>3</sub>/Spiro-MeOTAD/Ag reached 300 mV under AM1.5, 100 mW cm<sup>-2</sup> simulated illumination. Compared with MA<sub>2</sub>MnCl<sub>4</sub> materials exhibiting ultraviolet photoresponse, the a-MAMnI<sub>3</sub>-based device presented obvious photoresponse not only to ultraviolet light but also to visible light (530 nm green). Finally, the test with 2000 s on/off cycling demonstrated the good stability and repeatability of the device. This Pb-free and amorphous organic-inorganic hybrid material will benefit the future industrial production of green and low-cost optoelectronic logic devices, photodetectors, and optical memory devices.

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